

PATENT

## IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Present Application:

Applicants : Shin Hwa Li and Annie Tissier  
Title : A SEMICONDUCTOR STRUCTURE HAVING AN IMPROVED  
PRE-METAL DIELECTRIC STACK AND METHOD FOR  
FORMING THE SAME  
Docket No. : 98-P-009 (850063.529)  
Date : August 3, 2000

Prior Application:

Examiner : Kurt Eaton  
Art Unit : 2823  
Application No. : 09/061,667

Box Patent Application  
Assistant Commissioner for Patents  
Washington, DC 20231

PRELIMINARY AMENDMENT

Assistant Commissioner for Patents:

Please amend the above-identified application as follows:

In the Specification:

Amend the specification by inserting a new section before the "Technical Field" as follows:

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-- CROSS-REFERENCE TO RELATED APPLICATION

This application is a continuation of pending United States Patent Application No. 09/061,667, filed April 16, 1998. --

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In the Claims:

1. (Amended) A semiconductor structure, comprising:  
a substrate;